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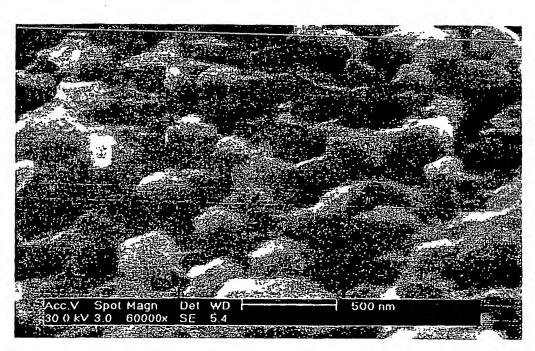
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(54) Title: AN IMPLANT AND A METHOD FOR TREATING AN IMPLANT SURFACE



(57) Abstract: The invention relates to a method for treating an implant surface intended for implantation into bone tissue wherein a microroughness comprising pores and peaks having a pore diameter of  $\leq 1 \mu m$ , a pore depth of  $\leq 500 nm$ , and a peak width, at half the pore depth, of from 15 to 150 % of the pore diameter is provided. The invention also relates to an implant comprising a surface having the above characteristics.

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